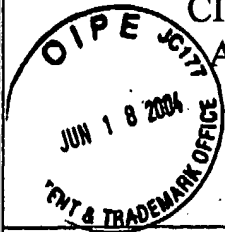


INFORMATION DISCLOSURE CITATION IN AN APPLICATION



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10/615,389

 APPLICANT
Motoki KAKUI, et al.

 FILING DATE
July 09, 2003

 GROUP
3663

U.S. PATENT DOCUMENTS

EXAMINER'S INITIALS	CITE NO.	Document Number Number-Kind Code(s) (if known)	Publication Date MM-DD-YYYY	Name of Patentee or Applicant of Cited Document	Pages, Columns, Lines, Where Relevant Passages or Relevant Figures Appear
		US			

FOREIGN PATENT DOCUMENTS

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						Yes	No
<i>AKU</i>		JP 11-317561 with English abstract	11/16/1999	Asahi Glass Co. Ltd.			
<i>AKU</i>		JP 2001-144358 with English abstract	05/25/2001	Asahi Glass Co. Ltd.			
<i>AKU</i>		JP 2001-102661 with English abstract	04/13/2001	Asahi Glass Co. Ltd.			
<i>AKU</i>		JP 2002-048935 with English abstract	02/15/2002	Asahi Glass Co. Ltd.			

OTHER ART (Including Author, Title, Date, Pertinent Pages, Etc.)

EXAMINER'S INITIALS	CITE NO.	Include name of the author (in CAPITAL LETTERS), title of the article (when appropriate), title of the item (book, magazine, journal, serial, symposium, catalog, etc.), date, page(s), volume-issue number(s), publisher, city and/or country where published.
<i>AKU</i>		"Fabrication of Bi_2O_3 -based Er-doped waveguide for integrated optical amplifiers" OFC 2002, Tuesday Morning, pp. 11-12
<i>AKU</i>		"Highly-nonlinear Bismuth Oxide-based glass fibers for all-optical signal processing" OFC 2002, Thursday Afternoon, pp. 567-568
<i>AKU</i>		"Broad-band 1.5 μm emission of Er^{3+} ions in bismuth-based oxide glasses for potential WDM amplifier" S. Tanabe, et al., Journal of Luminescence 87-89 (2000), pp. 670-672
<i>AKU</i>		"Broadband 1.5 μm Emission of Er^{3+} Ions in Bismuth-based Oxide Glasses for WDM Amplifier" Naoki SUGIMOTO, LEOS 99, pp. 814-815
<i>AKU</i>		"Fusion Spliceable and High Efficient Bi_2O_3 -based EDF for Short-length and Broadband Application Pumped at 1480 nm." Yutaka KUROIWA, OAA 2001, TUL5-1
<i>AKU</i>		"Novel Short-length EDF for C+L Band Amplification" Naoki SUGIMOTO, et al., OAA 2000, PD3-1 - PD 3-3
<i>AKU</i>		"Gain-flattened, extended L-band (1570-1620 nm), high power, low noise erbium-doped fiber amplifiers", S. Tanaka, et al., OFC 2002, Tech. Dig., ThJ3, pp. 459-461
<i>AKU</i>		"Ultra-Wideband L-band EDFA Using Phosphorus Co-Doped Silica-Fiber" OFC 2002, Tech. Dig., ThJ3, pp. 458
<i>AKU</i>		"Optical Amplification over Extended L-band Employing Silica-Based P/A1 Codoped EDF", Kakui, et al., The 2002 IEICE General Conference C-3-28(with English Translation)
<i>AKU</i>		"Silica based erbium doped fiber extending the L-band to 1620+ nm" IP. Byriel, et al., Ecoc 2001, Tu. L. 3.5, pg. 232-233
<i>AKU</i>		"Extending the L-band to 1620 nm Using MCS Fiber", A.J.E. Ellison, et al., TuA2-1 - 3, OFC2001
<i>AKU</i>		"Broadband Amplification Characteristics of Tellurite-Based EDF As", A. Mori, et al, Tech. Dig., p. 135, ECOC 1997

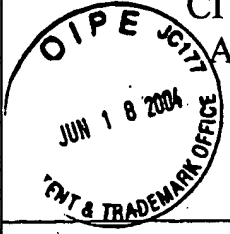
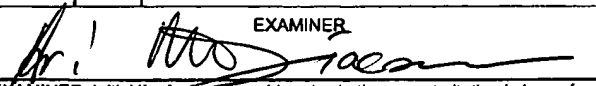
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